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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/065,277	09/30/2002	Roman Chistyakov	ZON-001		
23701	7590 08/30/2004		EXAMINER		
RAUSCHE P.O. BOX 38	NBACH PATENT LAV 37	MCDONALD, RODNEY GLENN			
BEDFORD,	MA 01730	ART UNIT	PAPER NUMBER		
			1753		

DATE MAILED: 08/30/2004

Please find below and/or attached an Office communication concerning this application or proceeding.



P-1	7-14-1-1				(, 1,				
		Applic	ation No.	Applicant(s)	1.				
Office Action Summary		10/06	5,277	CHISTYAKOV, RO	OMAN O				
		Exami	ner	Art Unit					
			y G. McDonald	1753					
The MAIL! Period for Reply	ING DATE of this communica	ation appears on	the cover sheet with the c	orrespondence ad	dress				
THE MAILING D. - Extensions of time mafter SIX (6) MONTH: - If the period for reply - If NO period for reply - Failure to reply within Any reply received by	STATUTORY PERIOD FOR ATE OF THIS COMMUNIC, asy be available under the provisions of its from the mailing date of this commun specified above is less than thirty (30) or its specified above, the maximum statut the set or extended period for reply will the Office later than three months after djustment. See 37 CFR 1.704(b).	ATION. 37 CFR 1.136(a). In no ication. days, a reply within the cory period will apply an lb. by statute, cause the	e event, however, may a reply be tin statutory minimum of thirty (30) day d will expire SIX (6) MONTHS from application to become ABANDONE	nely filed s will be considered timely the mailing date of this co	y. ommunication.				
Status									
1) Responsive	e to communication(s) filed	on 14 June 2004	1						
2a) This action			nis action is non-final.						
3) Since this a	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is								
	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.								
Disposition of Clain	าร								
4)⊠ Claim(s) <u>1-</u>	Claim(s) <u>1-50</u> is/are pending in the application.								
	4a) Of the above claim(s) is/are withdrawn from consideration.								
	Claim(s) is/are allowed.								
6)⊠ Claim(s) <u>1-</u>	Claim(s) <u>1-50</u> is/are rejected.								
7)☐ Claim(s)	Claim(s) is/are objected to.								
8) Claim(s)	Claim(s) are subject to restriction and/or election requirement.								
Application Papers									
9) The specific	ation is objected to by the E	xaminer.							
	The drawing(s) filed on is/are: a) □ accepted or b) □ objected to by the Examiner.								
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).								
	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).								
Priority under 35 U.S	S.C. § 119		•						
12)☐ Acknowledgi	ment is made of a claim for	foreign priority u	nder 35 U.S.C. § 119(a).	-(d) or (f).					
1.☐ Certifi									
applic	application from the International Bureau (PCT Rule 17.2(a)).								
* See the attached detailed Office action for a list of the certified copies not received.									
Attachment(s)									
) Notice of References	Cited (PTO-892)		4) Interview Summary (I	PTO-413)					
Notice of Draftsperso Notice of Draftsperso Notice of Draftsperso	n's Patent Drawing Review (PTO-	948)	Paper No(s)/Mail Date	e					
iniormation Disclosur الكمار Paper No/e\/Mail Data	rmation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) 5) Notice of Informal Patent Application (PTO-152)								



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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 5-10, 13, 14, 16, 19, 20, 22-31, 34, 37, 38 and 40-50 are rejected under 35 U.S.C. 102(b) as being anticipated by Kouznetsov (WO 98/40532).

Kouznetsov teach in Fig. 2 a *magnetron sputtering* device. The sputtering device has a sputtering chamber 1 and a target 9. *The substrate 13 is attached to some electrically isolating support 15 at the end of a wall.* (Page 8 lines 29-37; Column 9 lines 1-6) *A magnet or magnets 17* are mounted so that the north pole or poles are arranged at the periphery of the target and the south pole or poles at the center of the target 9. *One electrode, the anode, is formed by the electrically conducting walls 5 of the housing 3, which e.g. can be grounded.* The other electrode, *the cathode, is formed by the target 9*, which is thus negatively biased in relation to the anode. The substrate 13 can have some neutral electric potential. A gas inlet for a suitable gas to be ionized such as argon is indicated at 21. (Page 9 lines 7-20) It should be noted that the anode and cathode always have a gap in order to create the plasma. (Applies to Applicant's claim 41)

When increasing the voltage form zero and on between the anode 5 and the cathode 9, there will for some applied voltage appear an electric glow discharge. **The**



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gas in the region between the anode and the cathode will be partly ionized by electrons. The electrons will be somewhat trapped or confined by the magnetic field primarily moving in the areas of low magnetic field intensity. (Page 9 lines 21-25) Inherently ground state atoms exist because the gas is not ionized initially. Electrons are needed to ionize in the partially ionized state and the fully ionized state discussed below. (Applies to Applicant's claims 42, 43, 46 and 48)

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An electric discharge occurs between the cathode and the anode producing electrons trapped in the magnetic field by cooperation of the electric field produced by the applied voltage. (Page 4 lines 27-31)

When increasing the voltage and current more, there will appear the state comprising completely ionized plasma region 27, the region being stationary located above the surface of the target 9 and having a larger extension laterally, in the direction of the surface of the target 9 than the regions 23 of high electron and ion density used in ordinary sputtering. This state is made possible by the arrangement of the electric and magnetic fields crossing each other in the magnetron configuration.

Furthermore, in this state, owing to the considerable extension and the relative homogeneity and uniformity of the ionized plasma in the region 27, ions will hit the target surface more regularly and uniformly distributed over the surface. This will result in a more homogeneous wear of the target surface, as illustrated by the area delimited by the dashed line 29 in Fig. 5b. (Page 10 lines 13-23)

The power source is a pulse generator used primarily to produce coatings by sputtering. The power of each pulse can be in the range of 0.1 KW to 1 MW. *The*



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pulses can have a duration in the range of less than a hundred microseconds up to hundreds of microseconds and the intervals between pulses can range from milliseconds up to seconds. (Page 4 lines 14-23)

The voltage can be hundreds of volts up to several kilovolts. (Page 6 lines 24-25) The rise time is calculated form the time and voltage discussed above. (Applies to Applicant's claims 44, 45, 49 and 50)

The electric circuit will be generate at the frequency of the main supply typically with *a frequency of 50 or 60 Hz*. (Page 12 lines 14-15)

Alternating current is supplied from the power supply. (Page 6 lines 15-16)

Claims 1, 4, 5, 7, 13, 14, 16, 19-25, 27-29, 32, 33, 37 and 40 are rejected under

35 U.S.C. 102(b) as being anticipated by Mozgrin et al. "High Current Low-Pressure

Quasi-Stationary Discharge in a Magnetic Field: Experimental Research", Plasma

Physics Reports, Vol. 21, No. 5, 1995, pp. 400-409.

Mozgrin et al. teach a sputtering system as seen in Figure 1 having **a cathode** (1), **an anode** (2) and **a magnetic system** (3). (See Figure 1 pp. 401)

Figure 2 presents a simplified scheme of the *discharge supply system*. The supply unit involved *a pulsed discharge supply unit* and *a system for pre-ionization*. The *quasi-stationary* discharge supply unit consisted of a long line of W= 5.5 kJ maximal energy content, a switch and a matching unit. The pre-ionization system provided direct current. (Page 401)

A gas of argon is pre-ionized at a pre-ionized plasma density of



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